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In th Claims

- 1. (currently amended) An improvement in a compact electromagnetically pumped
 2 multiwavelength photonic device which includes an array of holes in a photonic
 3 crystal and a plurality of defects in the array of holes, each defect in the array
 4 defining a cavity, the improvement comprising a periodic patterned array of the
 5 plurality of nanocavities, each nanocavity defined in a photonic crystal in which each
 6 nanocavity is lithographically formed to define having a corresponding
 7 predetermined spectral response of each nanocavity, so that said plurality of
 8 nanocavities forming a the periodic patterned array of nanocavities collectively
- 2. (currently amended) The <u>improvement photonic device array-</u>of claim 1 where said spectral response of each nanocavity is defined by the wavelength of the electromagnetic wave which is supported in the photonic crystal by said lithographically defined nanocavity.

define a supercavity in the photonic device.

- 3. (currently amended) The <u>improvement photonic device array of claim 1</u> where said spectral response of each nanocavity is defined by the polarization of the electromagnetic wave which is supported by said lithographically defined nanocavity.
 - 4. (currently amended) The <u>improvement photonic device</u> of claim 1 where said spectral response of each nanocavity is defined by the polarization and wavelength.

- 3 of the electromagnetic wave which is supported by said lithographically defined
- 4 nanocavity.
- 1 5. (currently amended) The improvement photonic device of claim 1 where the
- 2 photonic device comprises a laser and wherein said array of nanocavities is
- 3 employed in the laser.
- 1 6. (currently amended) The improvement photonic device of claim 1 where the
- 2 photonic device comprises a detector and wherein said array of nanocavities is
- 3 employed in the detector.
- 7. (currently amended) The <u>improvement photonic device</u> of claim 1 where the
- 2 photonic device comprises an optical gate and wherein said array of nanocavities is
- 3 employed in the all optical gate.
- 1 8. (currently amended) The improvement photonic device of claim 1 where the
- 2 photonic device comprises an all optical router and wherein said array of
- 3 nanocavities is employed in the all optical router.
- 9. (currently amended) The improvement photonic device of claim 1 where the
- 2 photonic device comprises a modulator and wherein said array of nanocavities is
- 3 employed in the modulator.

- 1 10. (currently amended) The improvement photonic device of claim 1
- wherein an active quantum well is included in the photonic device and wherein said
- 3 photonic crystal in which the array of nanocavities are defined is formed in the active
- 4 quantum well.
- 1 11. (currently amended) The improvement photonic device of claim 1 where
- 2 the photonic device comprises a vertical cavity surface emitting laser and wherein
- said array of nanocavities is employed in the vertical cavity surface emitting laser,
- 4 VCSEL.
- 1 12.(currently amended) The improvement photonic device of claim 11 wherein said
- 2 nanocavities each have a volume and wherein said volume of each of said
- 3 nanocavities is approximately a cubic half-wavelength ($\lambda^3/2$).
- 1 13. (currently amended) The improvement photonic device of claim 1 comprises an
- 2 array of lasers each including an array of nanecavities and where at least one
- 3 nanocavity-laser is used as a pump for an adjacent nanocavity-laser.
- 1 14. (currently amended) The improvement photonic device of claim 1 further
- 2 comprising a nonlinear optical material filling said holes in the photonic crystal in
- which the array of nanecavities are defined.

- 1 15. (currently amended) The improvement photonic device of claim 14
- wherein said photonic device with the array of nanocavities defined in the filled
- 3 photonic crystal comprises a tunable nanocavity-laser, detector, router, gate or
- 4 spectrometer array.
- 1 16. (currently amended) The improvement photonic device of claim 14 further
- 2 comprising means for changing optical or electrical properties of said nonlinear
- 3 optical material in each of said nanocavities.
- 1 17. (currently amended) The improvement photonic device of claim 1 where said
- 2 photonic crystal in which said array is defined comprises a Si-Ge material on a
- 3 silicon substrate disposed on an insulator.
- 1 18. (currently amended) The improvement photonic device of claim 17
- 2 further comprising a silicon slab waveguide or integrated circuit integrated with said
- 3 array of nanocavities.
- 1 19. (currently amended) The improvement photonic device of claim 17 further
- 2 comprising a nonlinear optical material filling said photonic crystal and means for
- 3 changing optical or electrical properties of said nonlinear optical material
- 4 surrounding each of said nanecavities.

- 1 20. (currently amended) The improvement photonic-device of claim 1 further
- comprising a waveguiding layer disposed adjacent to said array of nanecavities, said
- 3 waveguiding layer being transparent to light from said array and critically coupled to
- 4 said nanocavities in said array.